

Graphene-Enabled Silicon-Integrated Radiation Detector for Low Penetrating Particles



The 40th RD50 Workshop

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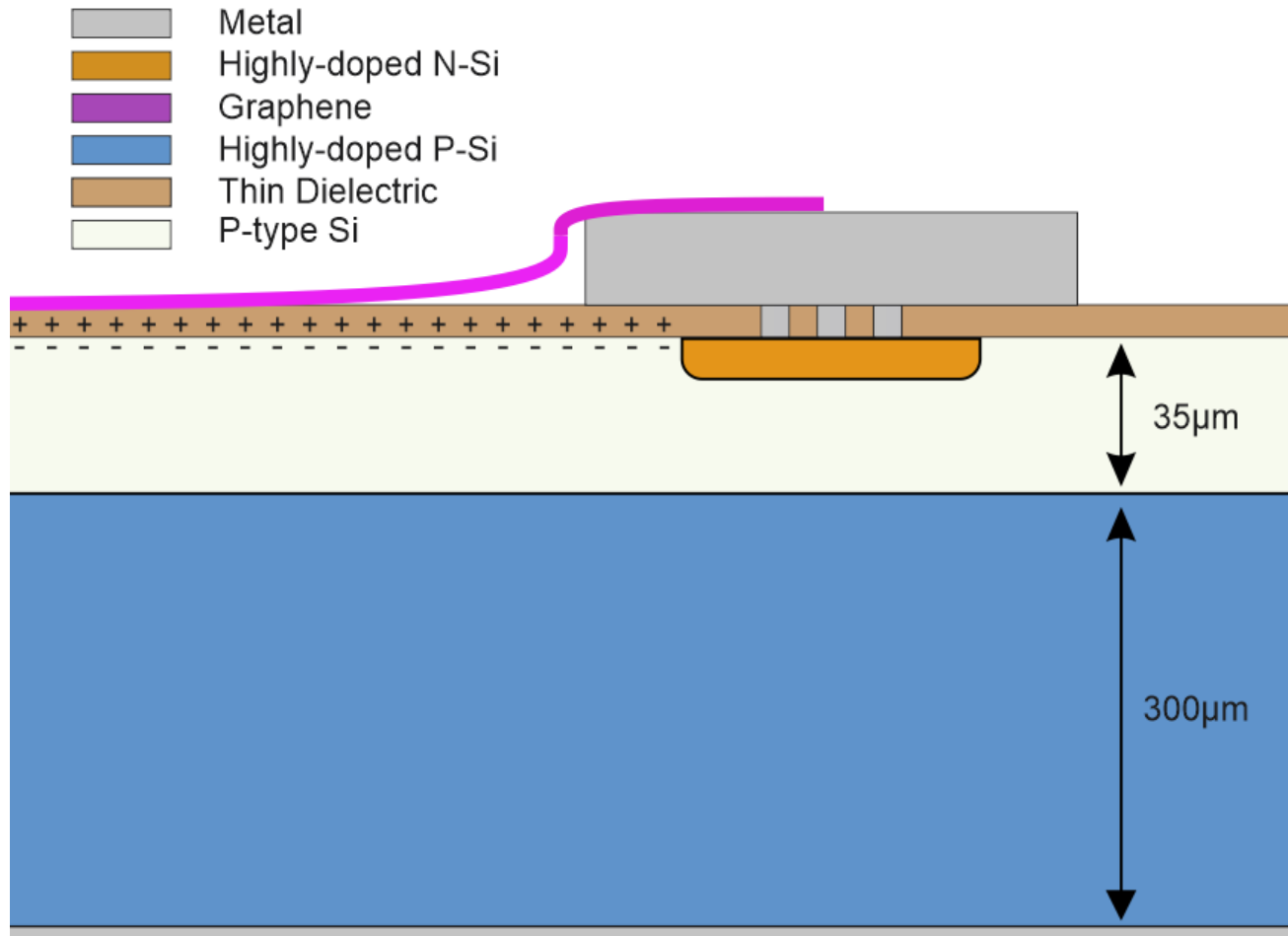
Introduction

- **Motivation**
- **Detector Concept**
- **Simulation**
- **Measurements**
- **Prospects**

Motivation

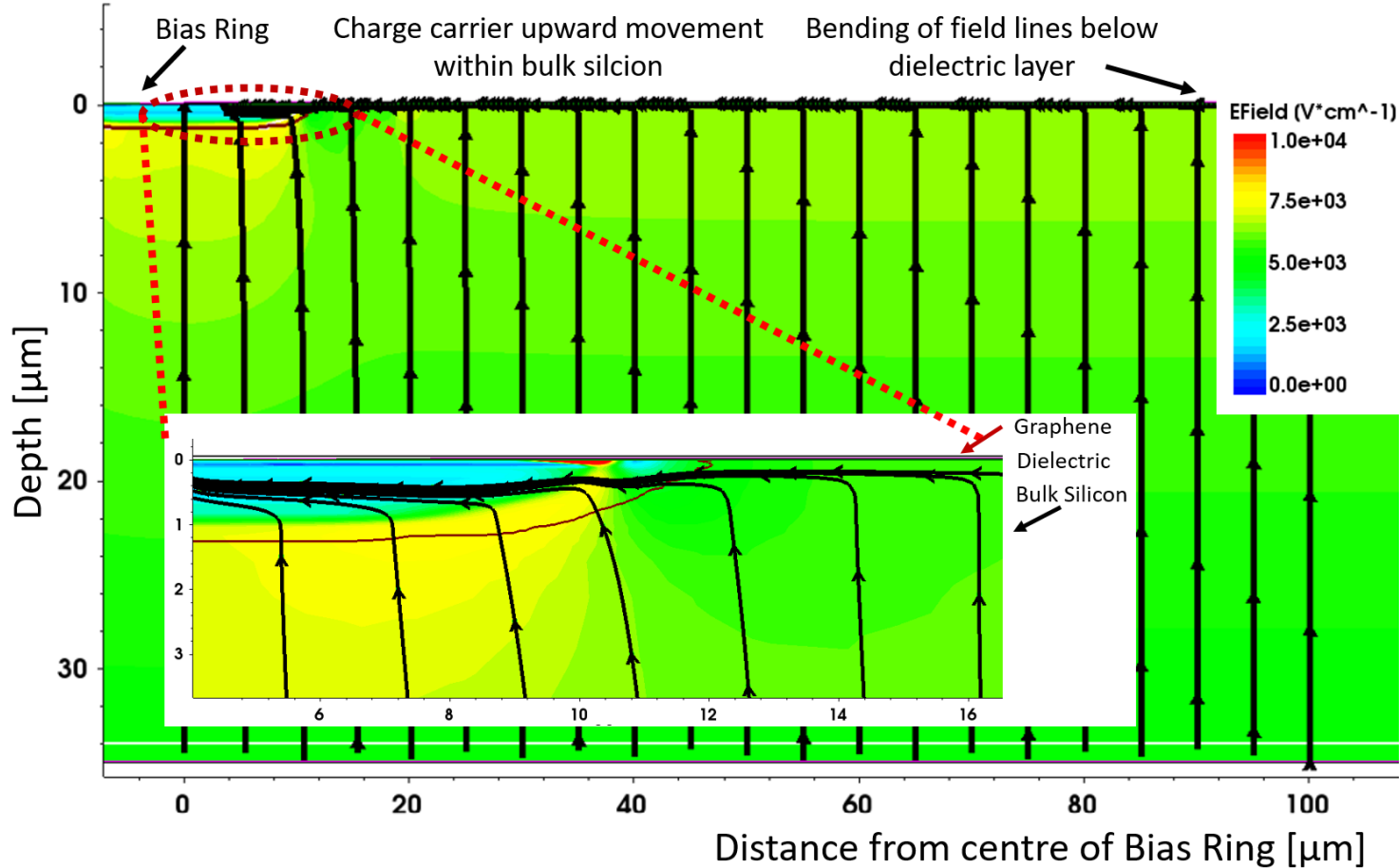
- **We wanted to create a “junction” with a minimum dead layer.**
- **We are interested in detecting low-penetrating particles such as ions, electrons, protons and “Soft X-rays”**
- **“Soft X-rays” can be used to study biological samples.**
- **Specifically we want to build a detector capable of studying X-rays with an energy in the so-called “water window”, between the Carbon and Oxygen edges (282 eV to 533 eV – Carbon and Oxygen being present in all biological samples).**

Detector Concept – Graphene-on-Insulator-on-Silicon (GIS)



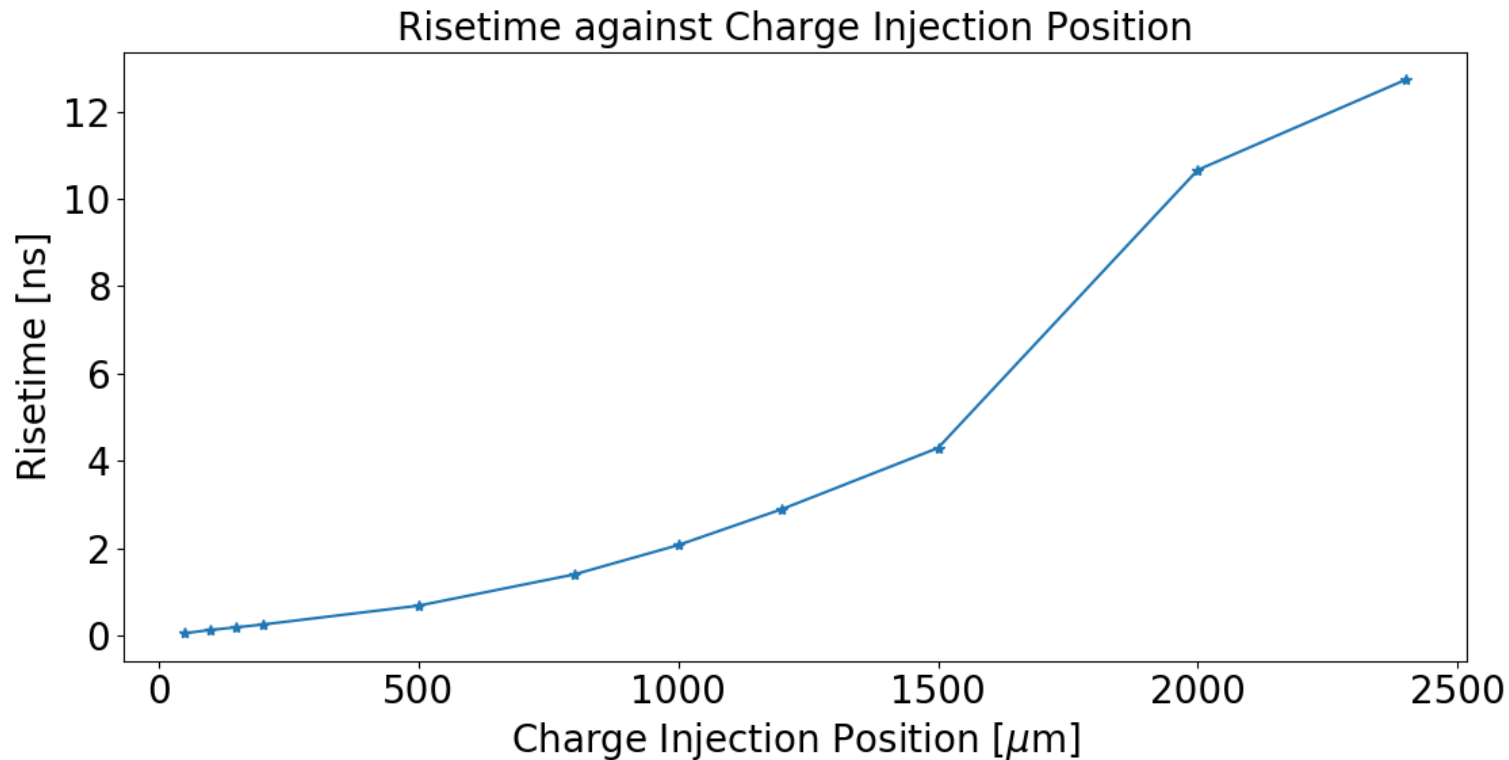
- Absorption layer (the 35µm Si) and bulk Si (the 300µm Si)
- **Graphene placed on top of thin dielectric (3nm) in electrical contact with metal.**
- Reverse bias applied to metal with ohmic contact to the highly-doped N región.
- Detector depletes under the N-electrode and under all regions of the detector with Graphene on top.
- An inversión layer is present at the interface of Oxide/Silicon
- **Dead región is defined by the thickness of the oxide. -> 3nm**

TCAD Simulation



- TCAD model developed using Sentaurus TCAD.
- Graphene model doesn't exist, instead a modified model of polysilicon used.
- Image shows Electric field lines.
- Charge carrier shows upward movement within the bulk silicon.
- **Bending of the lines at the Surface , below the dielectric layer towards the bias ring(Highly doped N region).**

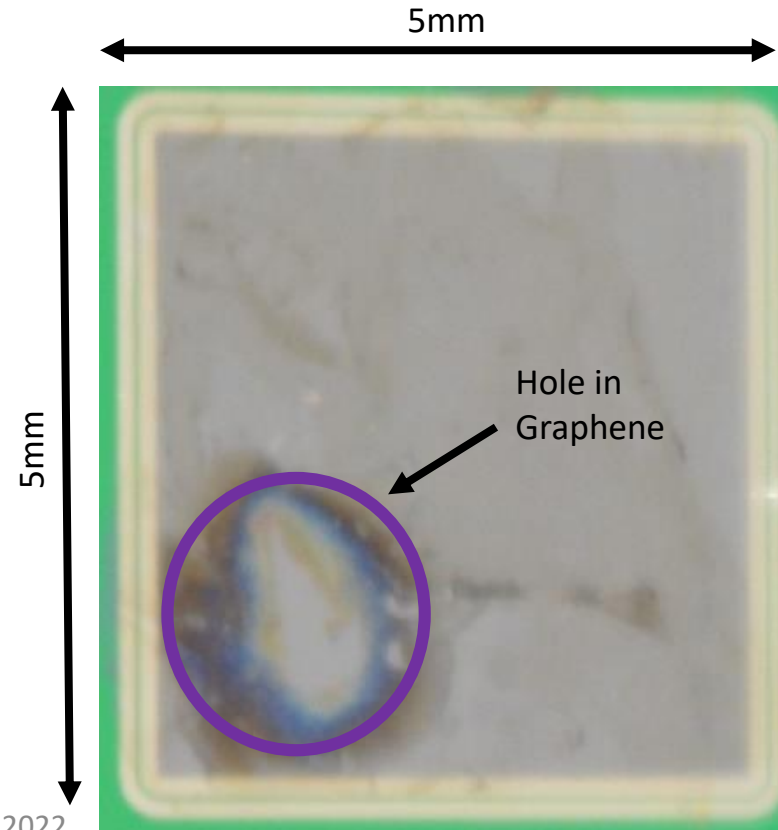
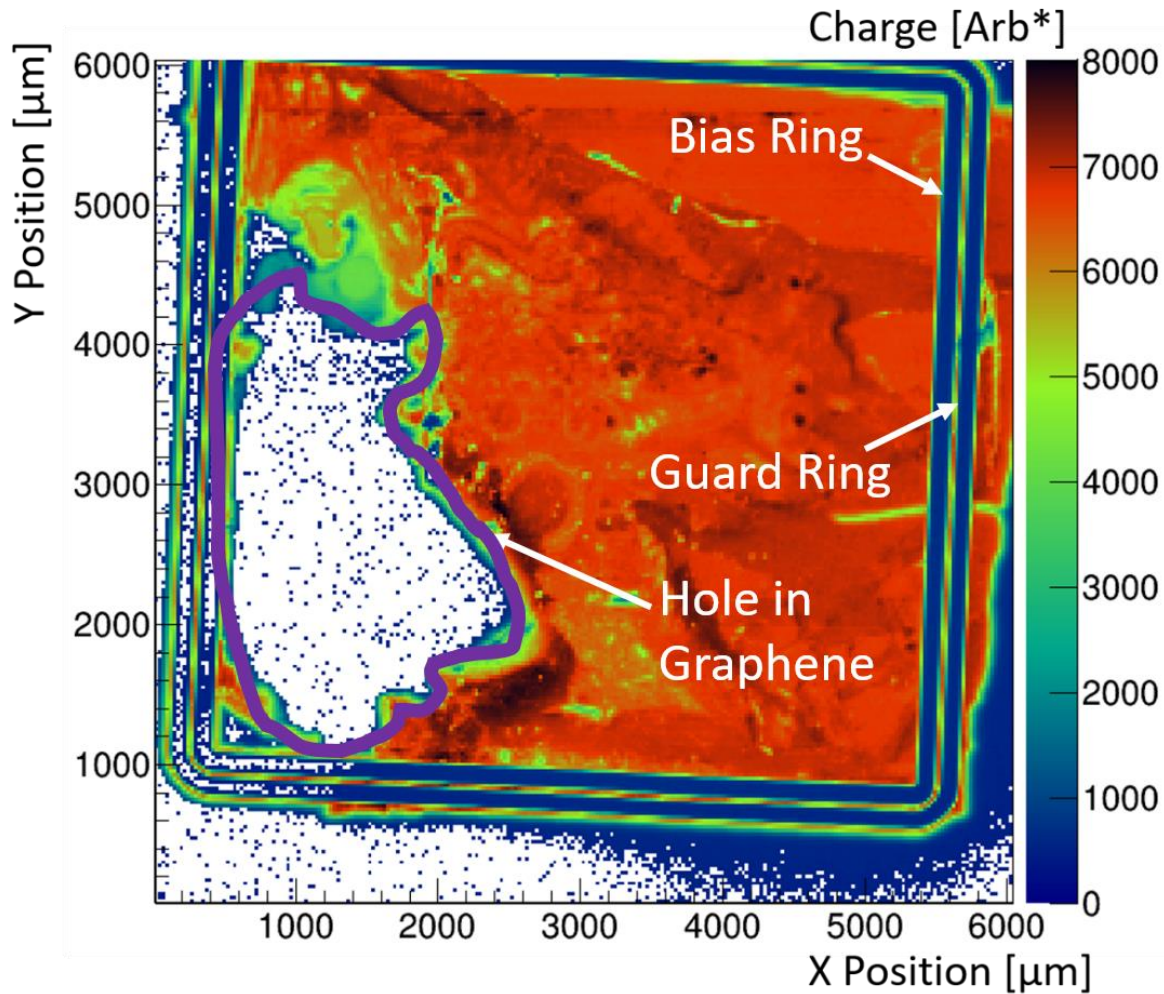
Simulation



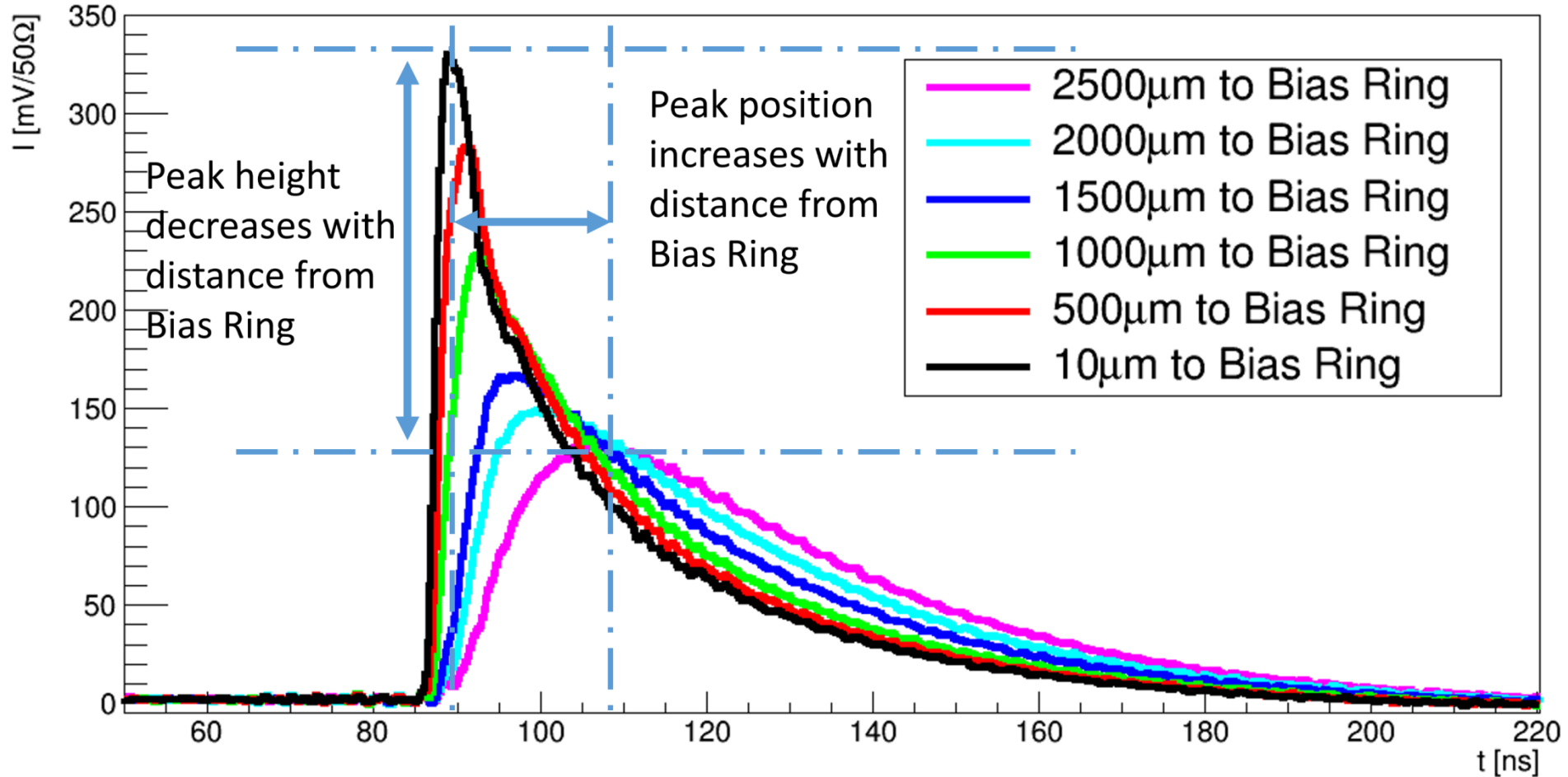
- **Simulation** shows that the risetime of the signal is dependant on the initial charge injection position.
- This is due to the difference in time required for the charge to travel along the surface of the detector.
- The **risetime** is proportional to both the distance to the collection electrode and the resistance of the device below the surface.

TCT

- 2D TCT scan of entire detector area using a Blue laser (405nm).
- Charge collected over entire area is **uniform**.
- The region where there is a hole in the graphene shows zero charge collected.

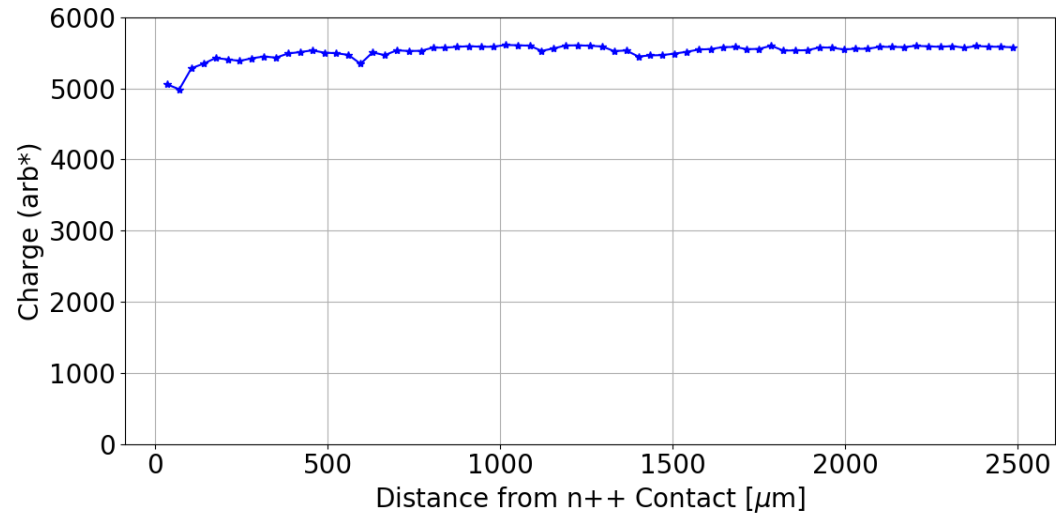


TCT



TCT

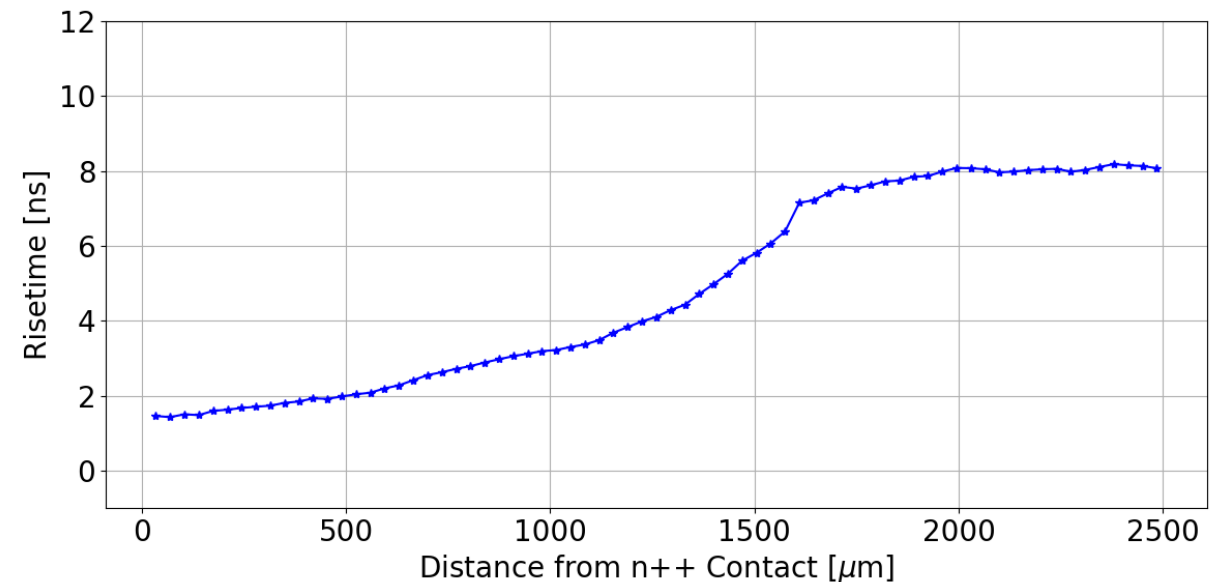
Charge



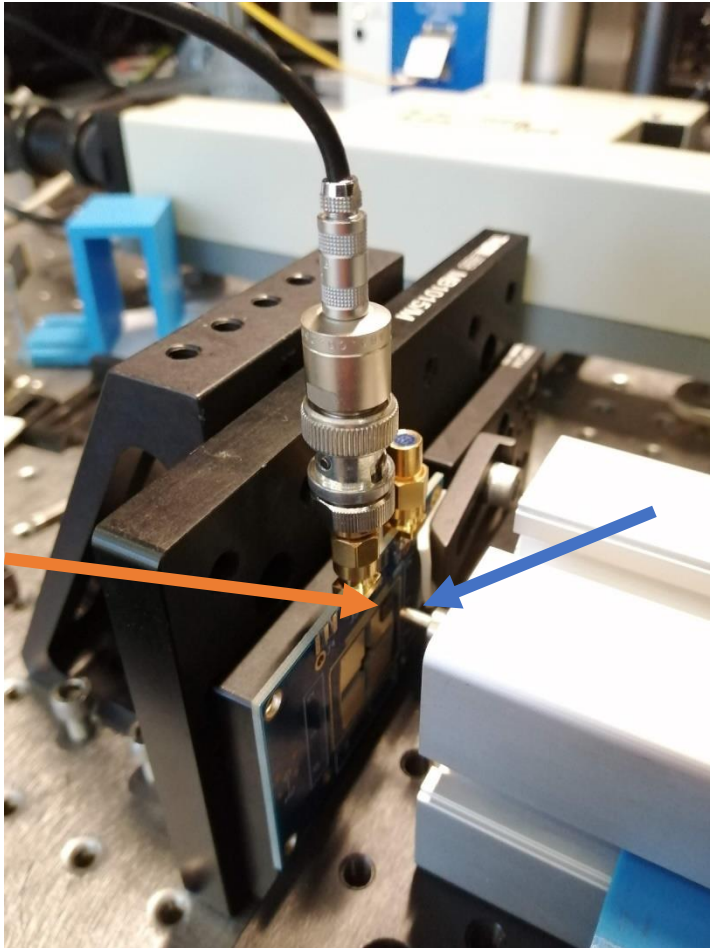
- **Charge** as function of injection position is uniform.
- Collection time and risetime can be different but all charge is collected.

- Measurements show that the **risetime** of the signal is dependant on the initial charge injection position.
- As expected from the simulation

Risetime



Photoresponsivity Setup

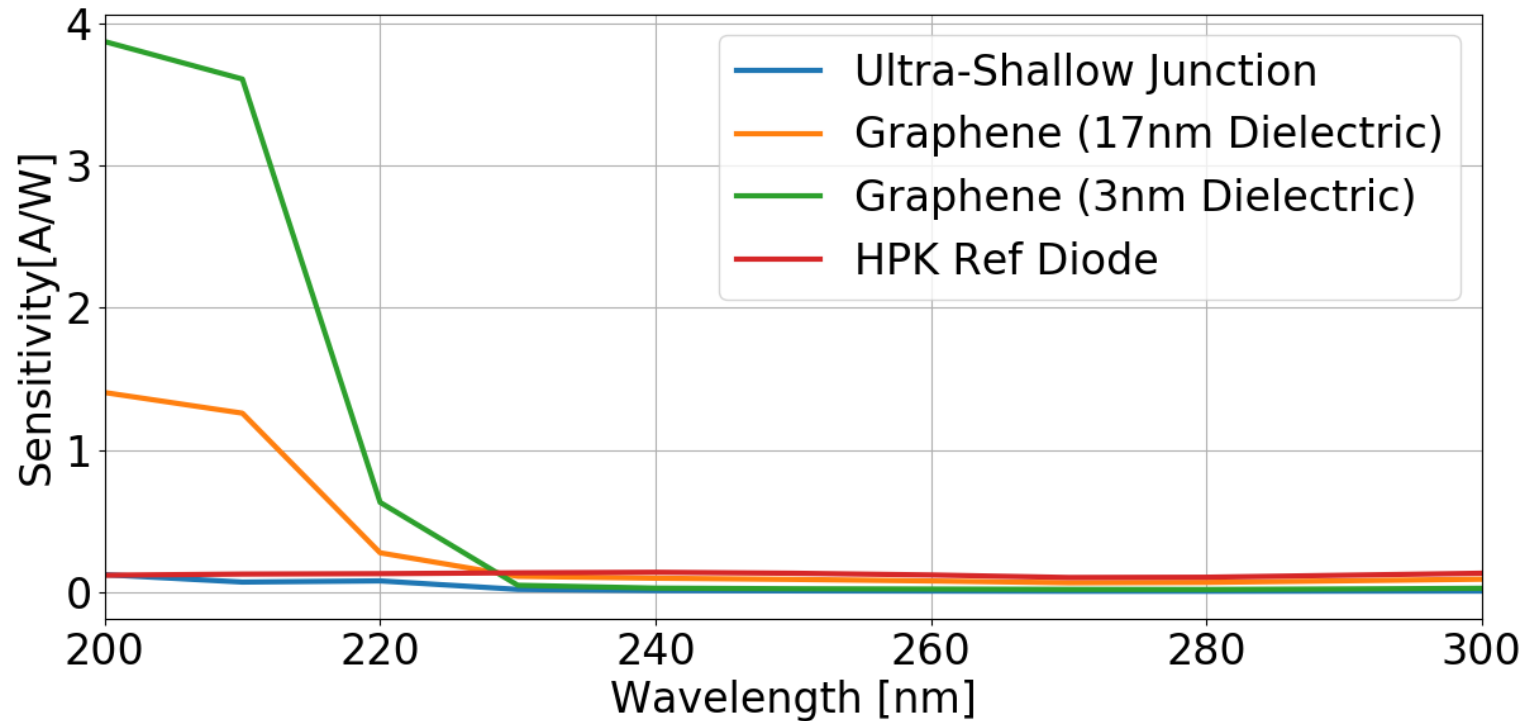


Detector

Output from Monochromator

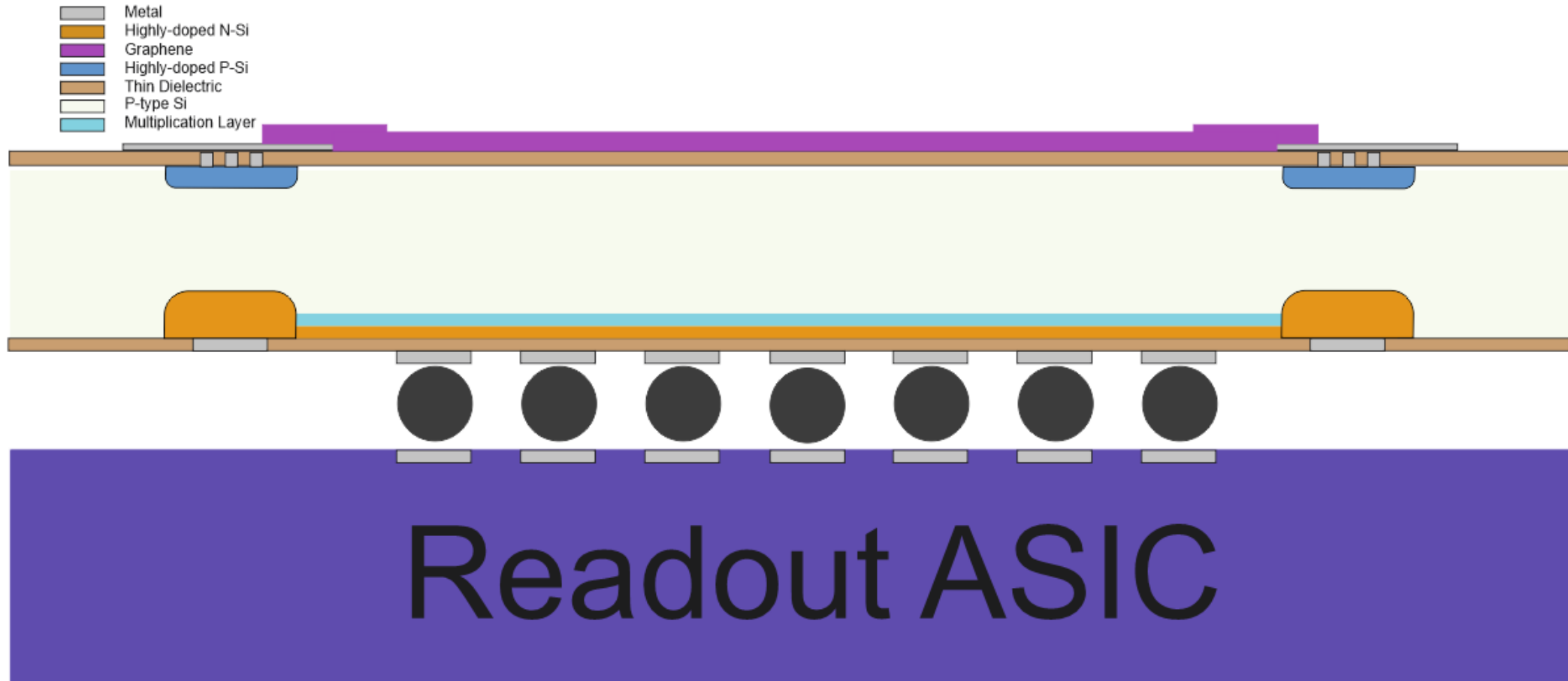
- **Monochromator** system used to modify the wavelength of light (200-800nm).
- The detector was biased to a **fixed voltage** and a sweep of wavelength performed.
- The **photocurrent was measured as a function of wavelength**.
- The responsivity was then calculated based on measurements of a **calibrated** HPK diode.
- All measurements performed in the Detector Development Lab at the **University of Glasgow** with the help of Dr Dima Maneuski. (Dima.Maneuski@glasgow.ac.uk)

Photoresponsivity



- Photo response of fabricated detectors show a variety of responses.
- To note the **max responsivity** of a silicon detector at 200nm is 0.17A/W
- The HPK reference diode shows good sensitivity at the full wavelength range.
- The devices with graphene show a superior response at wavelengths below 230nm.
- It is thought that the graphene must undergo gating (which is voltage dependant) in order to collect light at these wavelengths.
<https://www.sciencedirect.com/science/article/abs/pii/S1748013210001623?via%3Dihub>
- Main feature is that the devices are active at the full wavelength range.
- **Penetration depth of light of 200nm is approx 4nm.**

Prospects – AC-LGAD coupled with GIS



Conclusions

- **A device with a minimum dead area has been presented, which has been made utilizing the, almost, transparent nature of graphene.**
- **The device has a uniform charge collection across the entire area but the shape of the signal varies depending on the point of charge interaction.**
- **An LGAD device with this window could be produced for imaging of soft X-rays and DUV light.**
- **Next stage is in production. The first LGAD device with this transparent window will be produced at CNM this year using the AC-LGAD technology.**



Acknowledgements

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Project references: SPID202000X118404SV1

Thanks for your attention!

Backup

Simulation Model

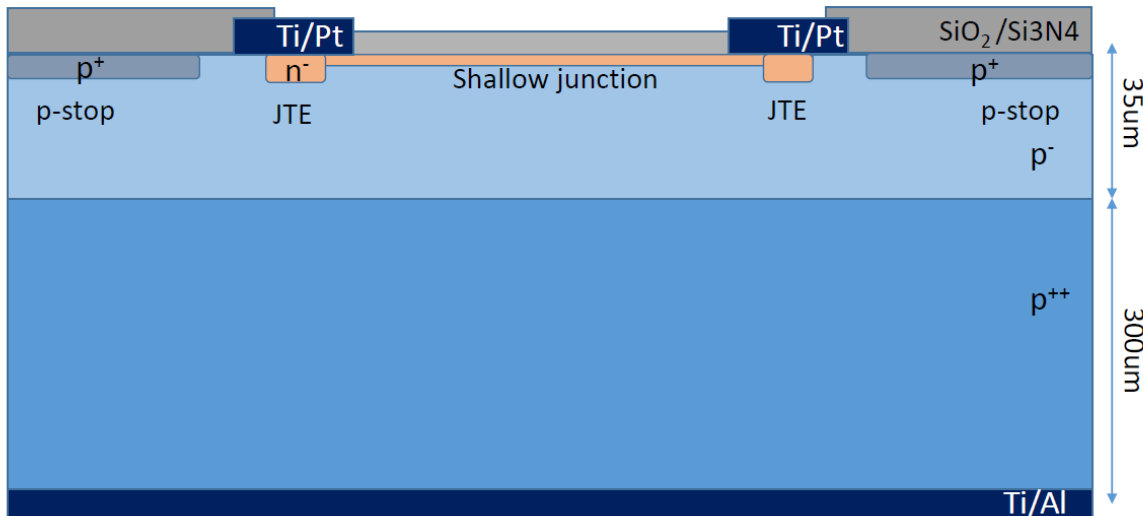
TABLE I. Material parameters of Graphene used for model¹⁶.

Parameters	Description	Value
$E_G(\text{eV})$	Bandgap	0
χ	Permittivity	25
$\mu_n(\text{cm}^2/\text{Vs})$	Electron mobility	10,000
$\mu_p(\text{cm}^2/\text{Vs})$	Hole mobility	10,000
X(kg/mole)	Affinity	4.248
v_{sat}	Electron saturation velocity	4×10^7

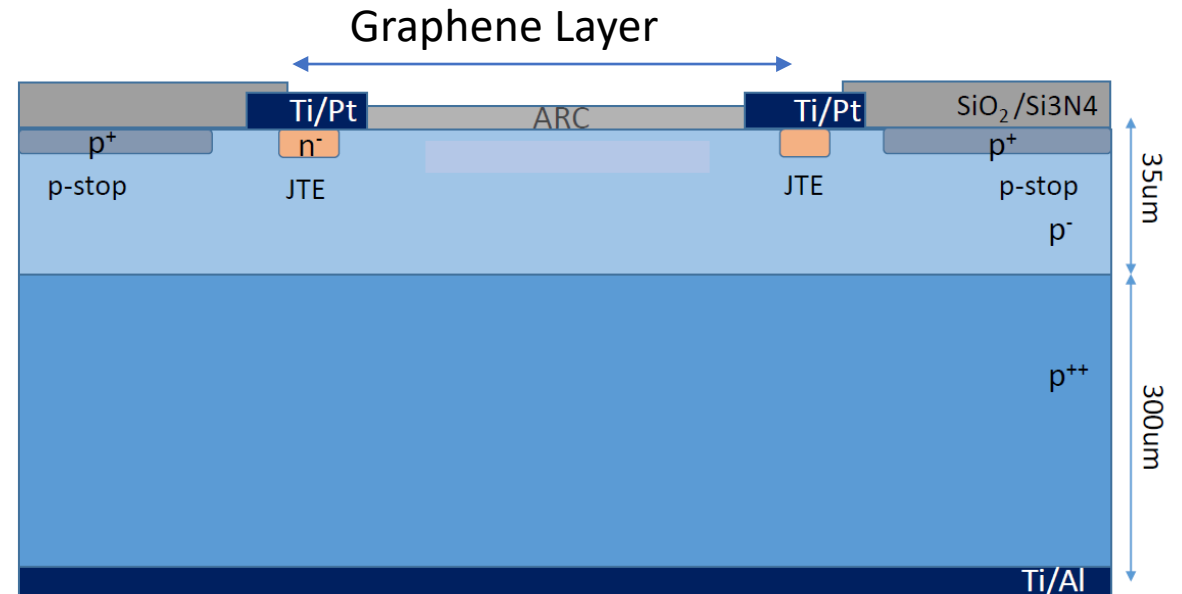
¹⁶ K. J. Singh, T. Thingujam, and M. Kumar, "Tcad based modeling and simulation of graphene nanostructured fet (gfet) for high frequency performance," ADBU Journal of Engineering Technology (AJET) 6, 49 (2017).

Si Detectors

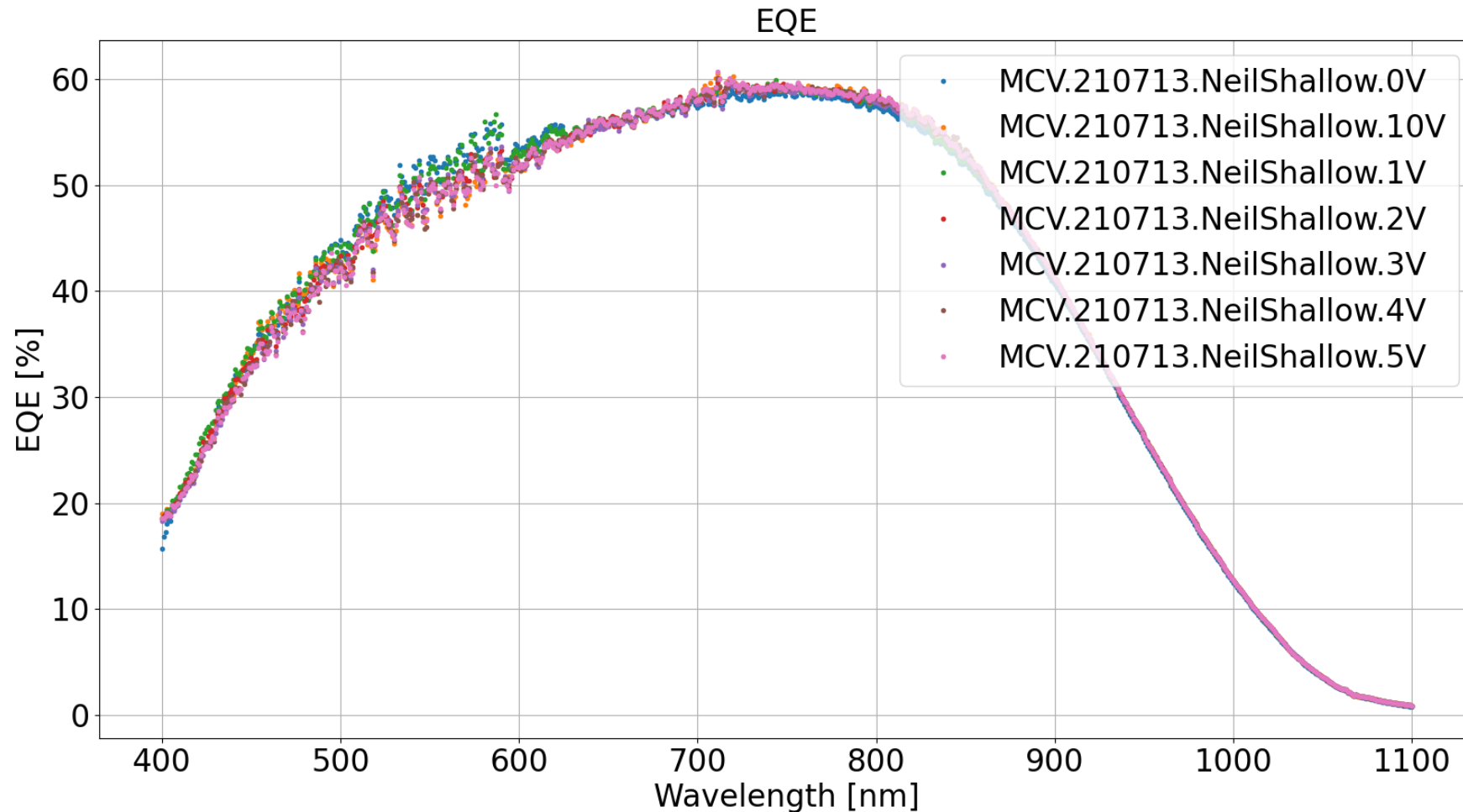
W2
 Active bulk 35 μm
 JTE
 P shallow junction
 S1 and S3 with metal on the Surface
 S2 and S4 without metal



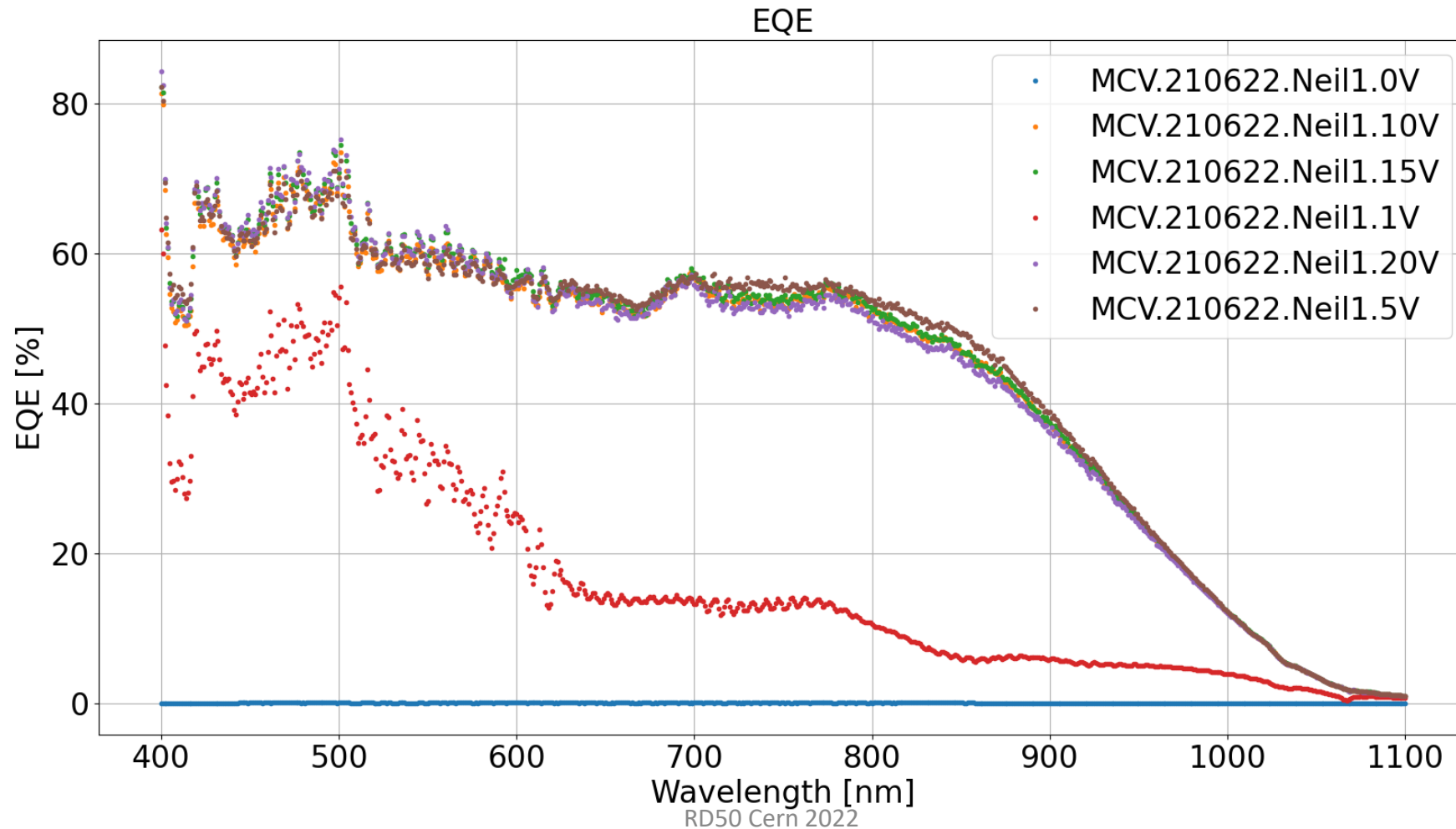
W3
 Active bulk 35 μm
 JTE
NO P shallow junction – Graphene
 Deposited
 S1 and S3 with metal on the Surface
 S2 and S4 without metal



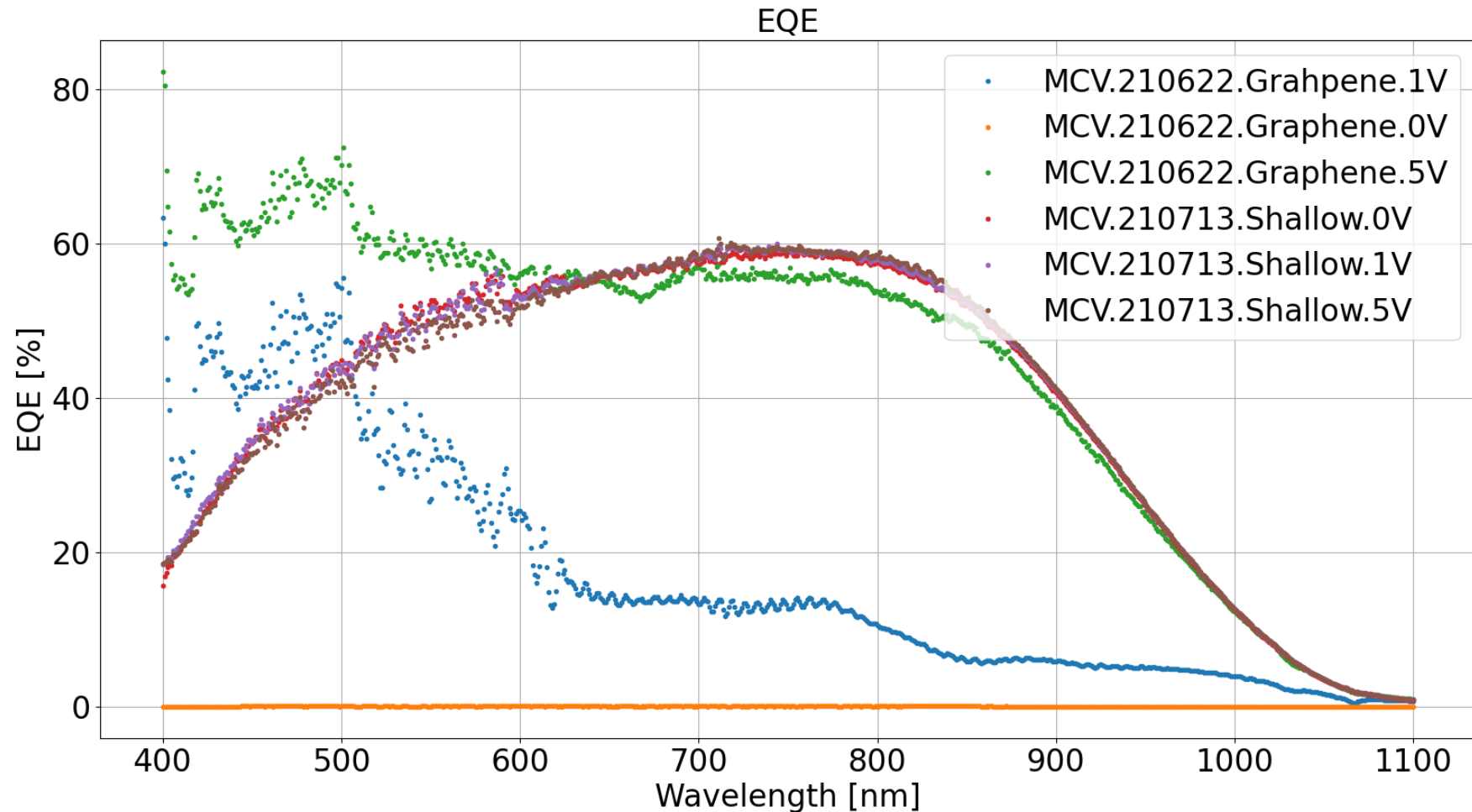
Measurements of EQE- ShallowImplant



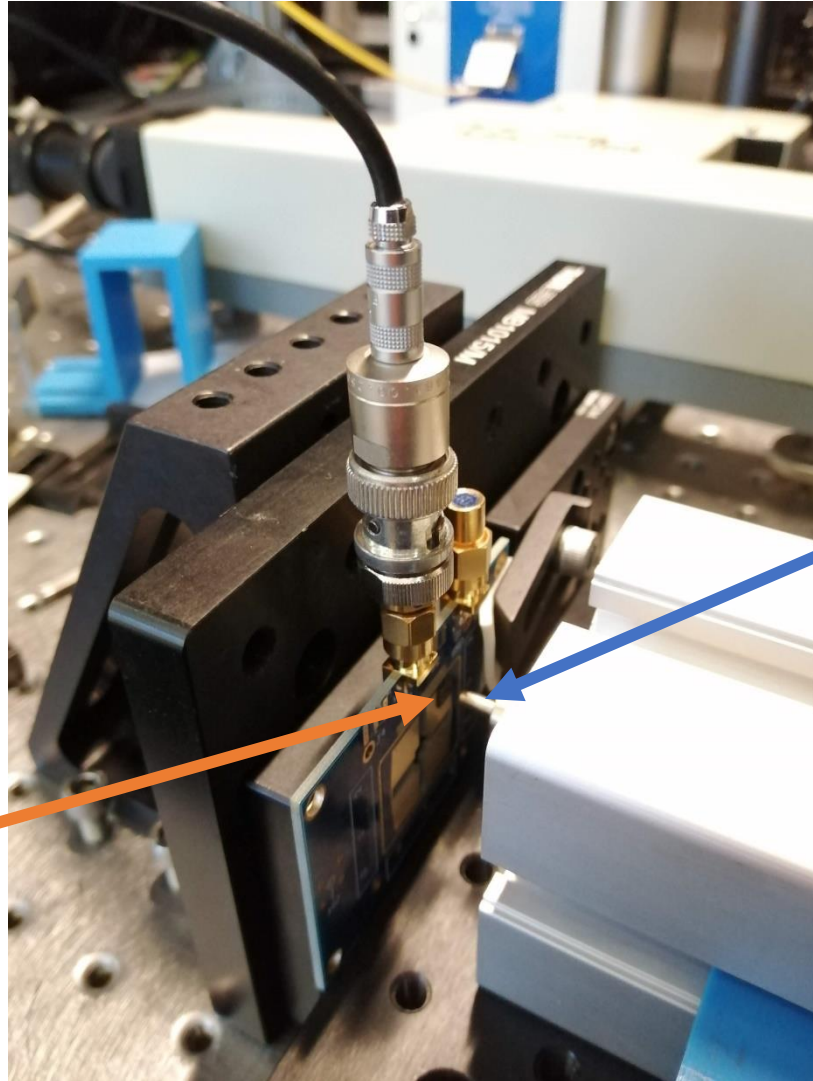
Measurements of EQE– NoImplant with Graphene



Measurements of EQE– Comparison



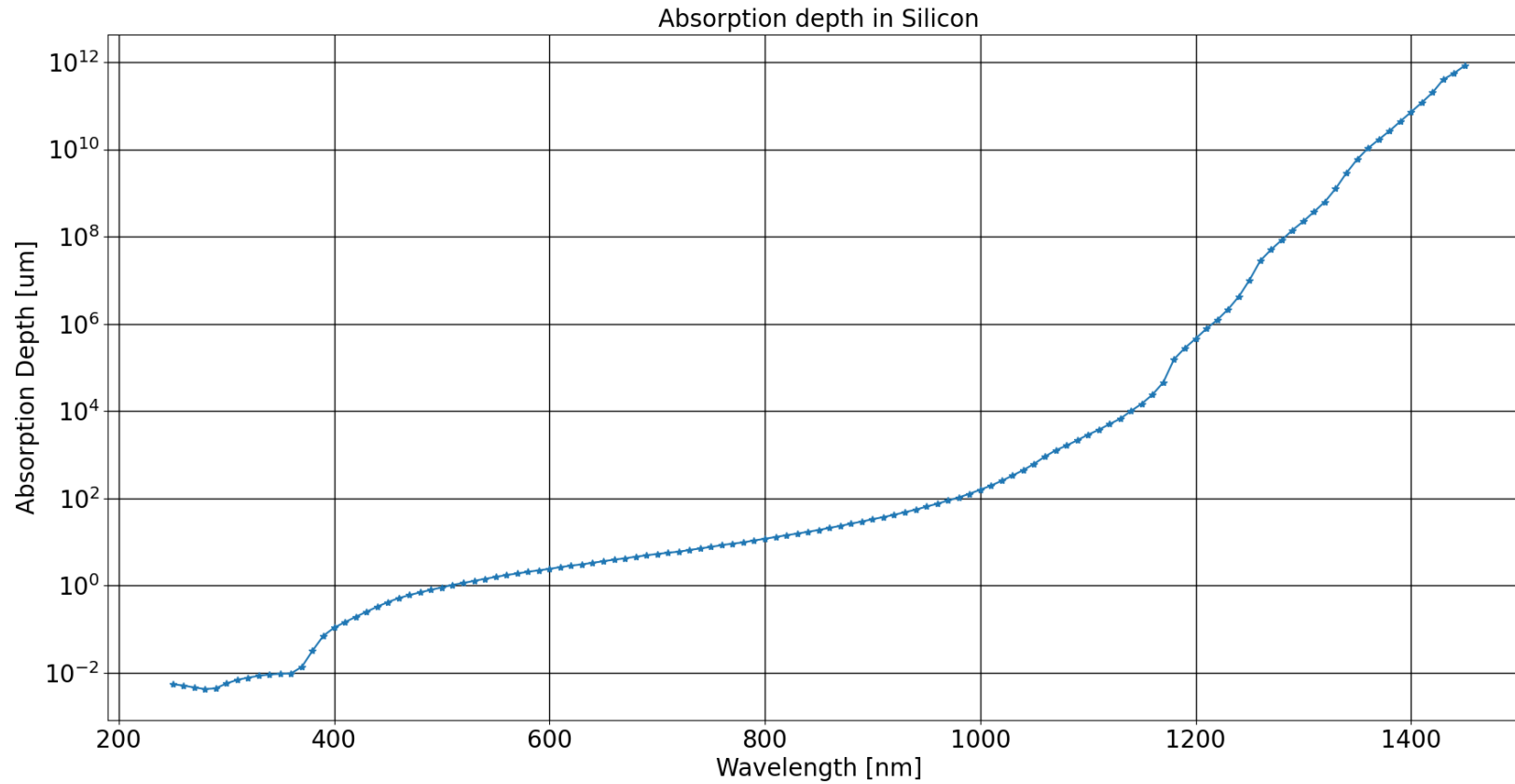
Setup



Detector

Output from
Monochromator

Absorption Depth in Silicon



Absorption depth in silicon

